

1st announcement

Celebrating 40 years

40th anniversary International Symposium on Dry Process Symposium (DPS2018)

November 13(Tue) – 15(Thu), 2018

Nagoya University, Nagoya, Aichi, Japan

The past, present, and future on dry process

International Symposium on Dry Process (DPS2018) will be held at Nagoya University, Nagoya in Japan, on November 13 to 15, 2018. The Symposium covers all aspects of the rapidly evolving fields of dry processes, including but not limited to plasma etching and deposition processes, diagnostics and modeling of plasmas and surfaces, and surface modifications by plasmas. The DPS has provided valuable forums for in-depth discussion among professionals and students working in this exciting field.

Website: <http://www.dry-process.org/2018/>



2018

2018 40th Nagoya

2017 Tokyo TECH

2016 Sapporo

2015 Awaji island

2014 Yokohama

2013 Jeju-Korea

2012 Tokyo

2011 Kyoto

2010 Tokyo TECH

2009 Pusan-Korea

2008 Tokyo

2008 30th

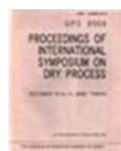
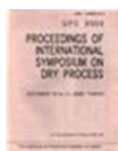
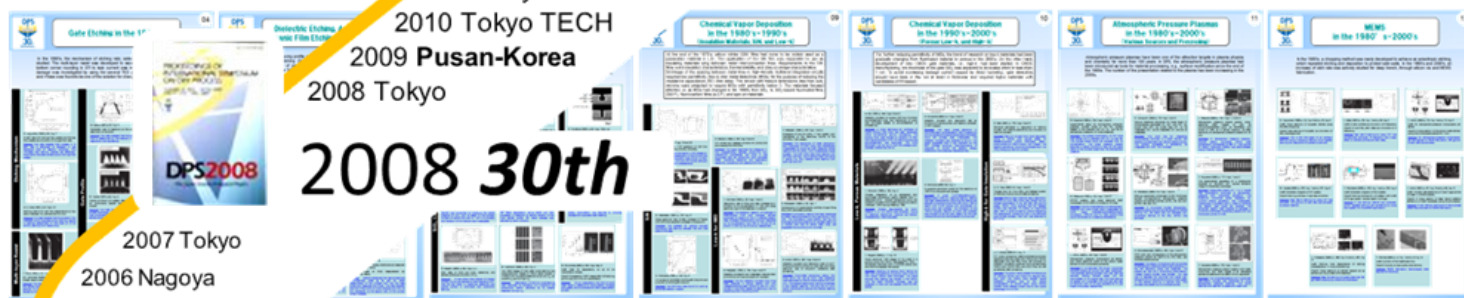
2007 Tokyo

2006 Nagoya

2005 Jeju-Korea

2004 Tokyo

**Submission deadline:
July 13, 2018**



1998 20th

1988 10th

1979 1st